Dr. Khademhosseini received "the 2010 AIChE Colburn Award".

Dr. Khademhosseini, Junior PI of Device/System Construction Thrust, received the 2010 American Institute for Chemical Engineers (AIChE) Allan F. Colburn Award for excellence in publications by a young member of the institute. This award is sponsored by E. I. DuPont de Nemours and Company and will be presented at the AIChE Annual Meeting.

Previous winners of the award are listed here:

http://www.aiche.org/about/awards/allanpcolburn.aspx

"AIChE" is the global professional community for over 40,000 chemical engineers in 93 countries.